

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S3	4	((("5,314,569") or ("6,346,189"))).PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/11/25 09:16
S7	2	("20020136681").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/11/25 09:19
S8	2	("20060292870").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/11/25 12:02
S9	30	(calibrated pore\$1)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/25 13:27
S12	66	(PRIBAT, DIDIER).in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/25 15:49
S13	4	(WEGROWE, JEAN-ERIC).in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/25 15:49
S14	10	(WADE, TRAVIS).in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/25 15:49
S15	8	(WEGROWE).in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/25 15:54

S17	804	(single crystal\$4 or single-crystal\$4) near2 zone	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/25 17:03
S18	79	(single crystal\$4 or single-crystal\$4) near2 zone and (alumina or aluminium oxide)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/25 17:03
S29	270	(epitax\$5) and ((electrochemical or electrochemical or electroplating or electro-plating) near2 (growth or deposition)) and (aluminium) and (cobalt)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 10:40
S33	975	alumina and nanoporous	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:19
S36	371	(alumina or sapphire or aluminium oxide) and nanoporous and (nanowire or nanotube or nanorod)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:21
S37	2	("6,359,288").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/11/26 13:39
S40	1	(anodic oxidation) and (single crystal aluminium substrate) and (alumina or aluminium oxide or sapphire)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:51
S41	1	(anodic oxidation) and (single crystal near2 aluminium substrate) and (alumina or aluminium oxide or sapphire)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:52
S42	1	(anodic oxidation) and (single crystal near4 aluminium substrate) and (alumina or aluminium oxide or sapphire)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:52

S43	1	(anodic oxidation) and (single crystal near4 aluminium near2 substrate) and (alumina or aluminium oxide or sapphire)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:53
S44	1	(anodic oxidation) and (single crystal near4 aluminium near4 substrate) and (alumina or aluminium oxide or sapphire)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:53
S45	4	(anodic oxidation) and (single crystal same aluminium near4 substrate) and (alumina or aluminium oxide or sapphire)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:53
S47	2	(anodic oxidation or anodization) and (single crystal near4 aluminium near4 substrate) and (alumina or aluminium oxide or sapphire)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:54
S48	19	(anodic oxidation or anodization) and (single crystal near4 aluminium) and (alumina or aluminium oxide or sapphire)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 13:56
S49	12	(anodic oxidation or anodization) and (single crystal aluminium)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 14:01
S50	37	(advantage\$1 or benefit\$1) same (single crystal aluminium)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/26 15:25
S51	5	("3929527" "4325776" "4554030" "5216271" "5262361").PN. OR ("5782997").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2008/11/26 15:27
S53	10	(advantage\$1 or benefit\$1) same (single crystal substrate) and (anodic)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 07:30

S54	632	(advantage\$1 or benefit\$1) same (single crystal substrate) NOT S53	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 07:34
S55	2	single crystal aluminium substrate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 07:35
S62	886	((carbon nanotubes) or (nanowires)) and (porous) and catalyst and (aluminium or aluminum) and (@ad<"20041012" or @rlad<"20041012")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 08:42
S63	17	S62 and diffusion barrier	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:03
S64	129	S62 and electroplating	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:08
S66	148	S62 and (chemical vapor deposition with catalyst)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:08
S67	14	single crystal aluminium and monocrystalline silicon	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:23
S69	385	aluminium (deposition or thin film or metal film) and (monocrystalline or monocrystalline or single crystal or single-crystal) (silicon or substrate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:33

S70	310	aluminium (deposition or thin film or metal film) and (monocrystalline or monocrystalline or single crystal or single-crystal) (silicon or substrate) and (@ad< "20031013")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:34
S71	325	S62 and barrier	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:41
S72	48	S62 and barrier same catalyst	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:42
S73	1644	((carbon nanotubes) or (nanowires) or nanorods) and (porous or nanoporous or nano-porous) and catalyst and (@ad< "20041012" or @rlad< "20041012")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:43
S74	37	S73 and barrier with catalyst	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 09:43
S80	20	((anneal or annealed or annealing) same catalyst) and (magnetic field) and (carbon nanowire or nanotube) and (@ad< "20031013") NOT drug NOT skin NOT inkjet	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 10:53
S81	20	"6,894,359"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 12:33
S84	101	nanotube and nanoporous and transistor and (@ad< "20031013" or @rlad< "20031013")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 12:35

S85	2	("7,189,435").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/12/01 12:40
S87	2	("20020158342").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/12/01 12:40
S88	234	S73 and (chemical vapor deposition with (catalyst or cobalt))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 14:18
S101	712	silicon same diffusion same aluminium same titanium nitride same barrier and (@ad< "20031013")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/01 15:17
S107	1647	((carbon nanotubes) or (nanowires) or nanorods) and (porous or nanoporous or nano-porous) and catalyst and (@ad< "20041012" or @rlad< "20041012")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 08:44
S108	1	S107 and (chemical vapor deposition with (catalyst or cobalt) with bottom with pore)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 08:44
S109	5	S107 and ((chemical vapor deposition or CVD) with (catalyst or cobalt or Co) with bottom with pore)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 08:45
S110	25	S107 and ((chemical vapor deposition or CVD) with (catalyst or cobalt or Co) with (bottom or pore))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 08:46
S111	42	carbonyl metal and catalyst and chemical with deposition	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 08:57

S112	2	("5102647").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/12/02 09:05
S113	1060	cobalt with chemical with deposition	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 09:23
S114	7	cobalt with pore with chemical with deposition	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 09:23
S118	16	cobalt same pore with chemical with deposition NOT S114	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 09:47
S120	102	cobalt and pore with chemical with deposition NOT S114 NOT S118	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 09:48
S121	83	cobalt and pore with chemical with (vapor or gas) with deposition NOT S114 NOT S118	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 09:48
S122	2	("6362011").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/12/02 09:49
S128	67	nanowire and catalyst and alumina and (nanopore or nanoporous) and (@AD< "20041012")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/02 14:42
S129	10	((("4,472,533") or ("5,174,883") or ("5,198,112") or ("5,202,290") or ("5,581,091,")).PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/12/02 14:49

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